Thursday March 9th

10h00 – 12h00	Registration at the conference center The Strip at the High Tech Campus Eindhoven
12h00 – 13h00	Lunch
13h00	<u>Welcome</u> Opening by Dr. P.E. Wierenga Senior Vice President Philips Research Europe - Eindhoven
13h15	Start session 1 "Electronic Paper"
13h15 – 13h35	"Development of 5.1-inch High Speed SVGA Bistable BiNem [®] LCD for Electronic Paper Applications" Jacques Angelé, Nemoptic
13h35 – 13h55	"Experience the brighter world of visual DNA™" Michael Ryan, Ntera
13h55 – 14h15	<u>"Video-speed electronic paper based on electrowetting"</u> Rob Hayes, Liquavista
14h15 – 14h35	<u>"A new generation of e-readers takes off"</u> Alex Henzen, Irex
14h35 – 14h55	<u>"A Computer Simulation and material for Electrophoretic Displays"</u> Kimiya Takeshita, Mitsubishi Chemical
14h55 – 15h25	Coffee break
15h25	Start session 2 "3D Displays"
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15h25 – 15h45	"Novel autostereoscopic displays with user interaction" Klaus Hopf, Fraunhofer Institute for Telecommunications (HHI) "Optimization of wavelength selective parallax barrier displays"
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Friday March 10th

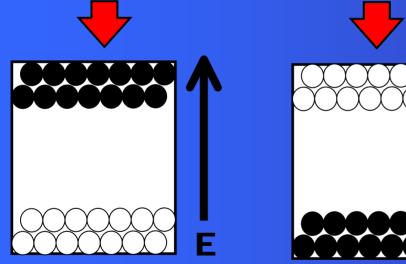
09h00	Start session 4 "Flexible Displays"
9h00 – 9h20	"TFT Backplanes on Flexible Foils: A Status Report" Nicholas Colaneri, Flexible Display Center, Arizona State University
9h20 – 9h40	<u>"Inorganic LTPS TFTs on metal for flexible AM-OLED displays"</u> François Templier, CEA-LETI
9h40 – 10h00	"Organic transistors and their application in active-matrix displays" Gerwin Gelinck, Polymer Vision
10h00 – 10h20	"Polymers behind the scenes: on how structured polymers enhance your displays" Dirk J. Broer, Technical University Eindhoven, Dept. Polymer Technology (SKT)
10h20 – 10h50	Coffee break (including 10h30 the SID-MEC General meeting)
10h50	Start session 5 "Signal Processing"
10h50 – 11h10	"The impact of new display technologies on HDTV broadcasting in Europe" Richard Salmon, HDTV Systems Project
11h10 – 11h30	<u>"Mobile Display Signal Processing"</u> Petri Nenonen, Nokia Research Center
11h30 – 11h50	<u>"Design consideration of field sequential display"</u> Erno Langendijk, Philips Research Europe
11h50 – 12h10	"Display System Architecture for LCD-TV" Gerben Hekstra, Philips Research Europe
12h10 – 12h30	<u>"Precise measurement of the light emission temporal behaviour of flat</u> <u>panel displays"</u> Pierre Boher, Eldim
12h30 – 13h30	Lunch
13h30 – 14h00	Introduction MiPlaza and open innovation Gerjan van de Walle and Hans Naus, High Tech Campus Eindhoven
14h00 – 14h05	Announcements
14h05 – 15h30	Visit MiPlaza, demonstrations and sponsor booths in sub-groups
15h30 – 16h30	Visit to the OTB company: OLED manufacturing line near Eindhoven airport

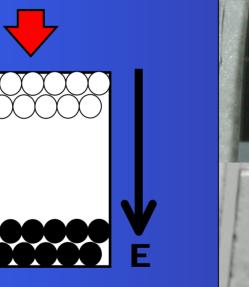
Model for the properties and behavior of electronic paper

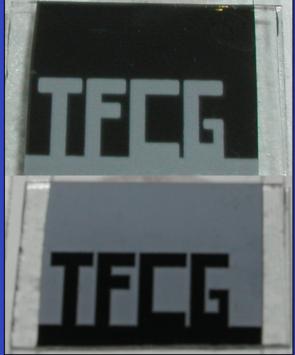
T. Bert, V. Degezelle, G. Van Steenberge, S. Van Put, P. Geerinck & H. De Smet

TFCG Microsystems – Elintec Ghent University **EPID**

Basic functioning







EPID

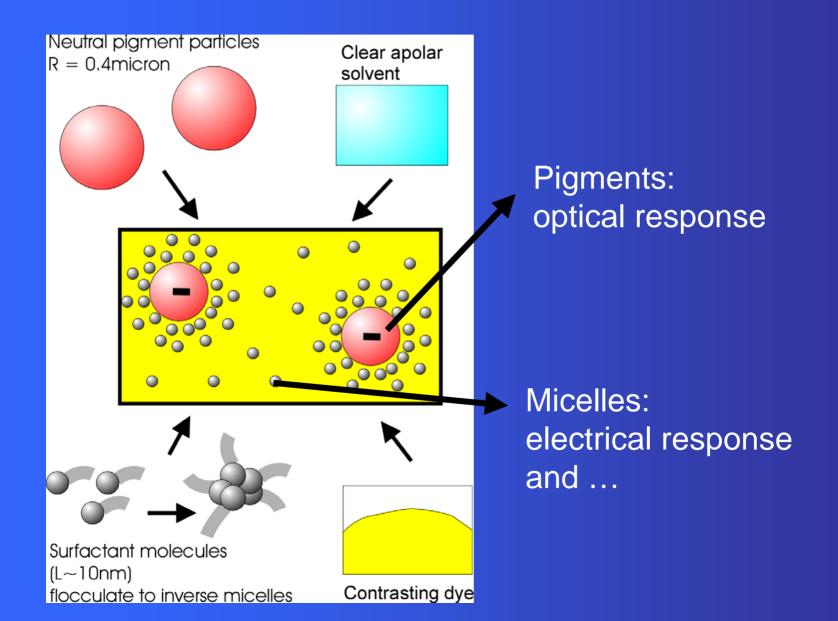
Benefits and Drawbacks

bistability
lightweight
readibility
flexibility

switching speed
no threshold
no colour
electrochemical complexity

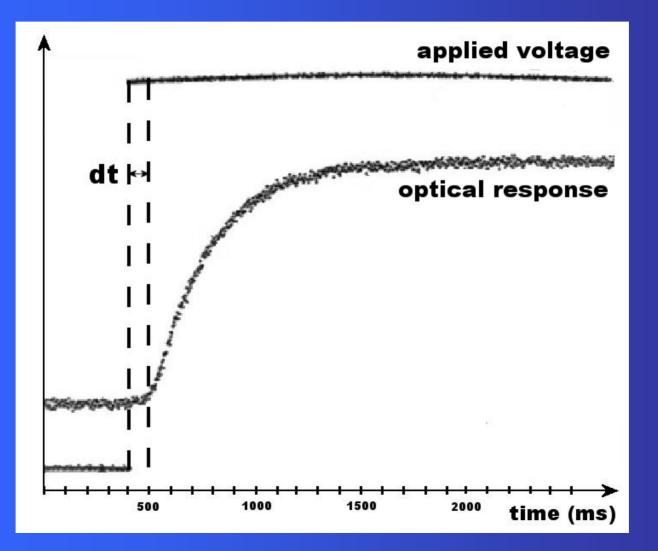


Particles inside an EPID



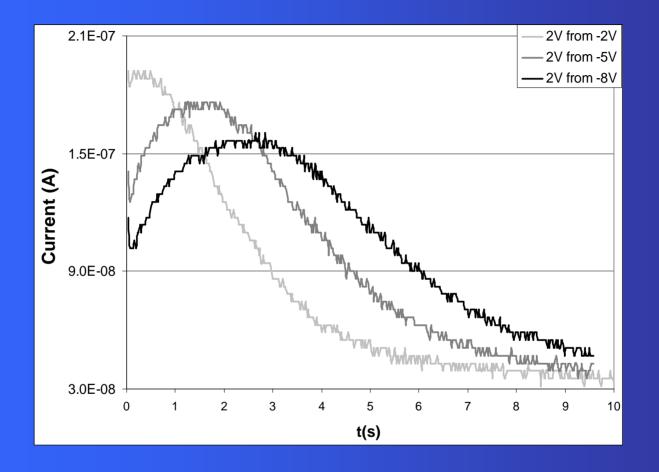
Optical response & delay time





EPID

Electrical dependence on previous voltage



Current peak broadens, becomes lower, later and more pronounced.

- Optimization of switching speed is pure chemical and physical process
- Intelligent display design
- Investigation of other display materials

There is a need for better understanding of display properties and a means to model behavior



- Gaussian distribution: average value measures drift, standard deviation measures diffusion.

 one-dimensional simulation: pixel dimension parallel to the field is much smaller than perpendicular.

$$n(x,t) = \frac{N}{\sqrt{2\pi}v_{diffusion}t} e^{-\frac{1}{2}\frac{(x-v_{drift}t)^2}{(v_{diffusion}t)^2}}$$



From charged particle distribution: transient currents, voltage dependence, ...

$$v(x,t,V_1,V_2) = \frac{dx}{dt} = \frac{\frac{dn(x,t,V_1,V_2)}{dt}}{\frac{dn(x,t,V_1,V_2)}{dx}}$$
$$J(t,V_1,V_2) = \int_{0}^{d} v(x,t,V_1,V_2)n(x,t,V_1,V_2)dx$$



From pigment distribution: delay time, switching speed,...

$$I(t, V_1, V_2) = I_0 s \int_0^t R(t_d) \left[\int_0^d n(x, t - t_d, V_1, V_2) e^{-\alpha a(d-x)} dx + \int_d^\infty n(x, t - t_d, V_1, V_2) dx \right] dt_d$$

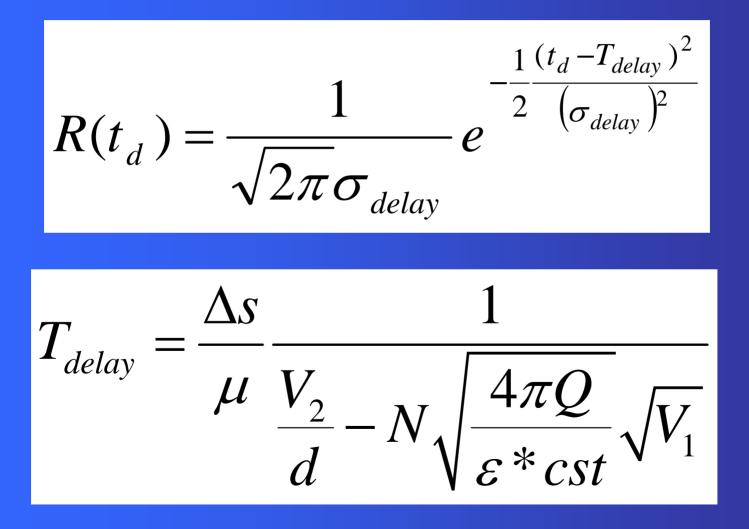
Theory

$$\varepsilon_0 \varepsilon_r \nabla E = \varepsilon_0 \varepsilon_r \frac{dE}{dx} = \rho(x) = n(x)e$$

$$\Delta E(t) \approx \frac{NQ}{\varepsilon} \frac{1}{\sqrt{2D}} \frac{1}{\left(t + \frac{Q * cst}{8\pi\varepsilon DV_1}\right)^{\frac{1}{2}}}$$

Reduce charge to increase field strength: centrifugation

Theory





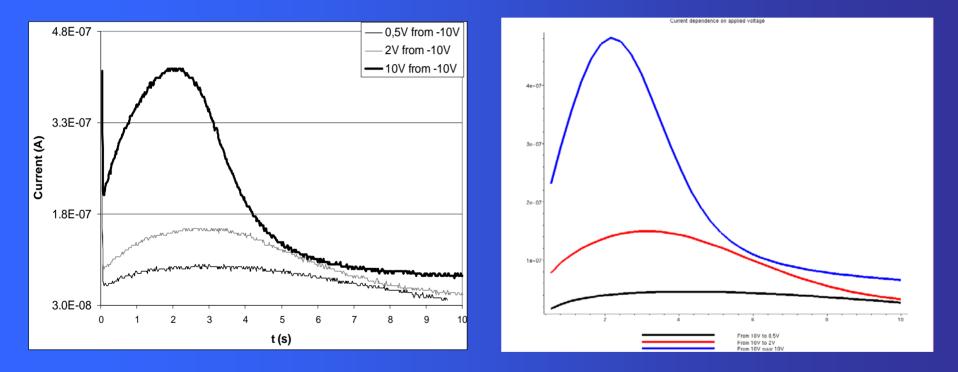
Physical Parameters



Link between model parameters (diffusion velocity, drift velocity,...) and real parameters (viscosity, temperature, charge, pigment radius,...)

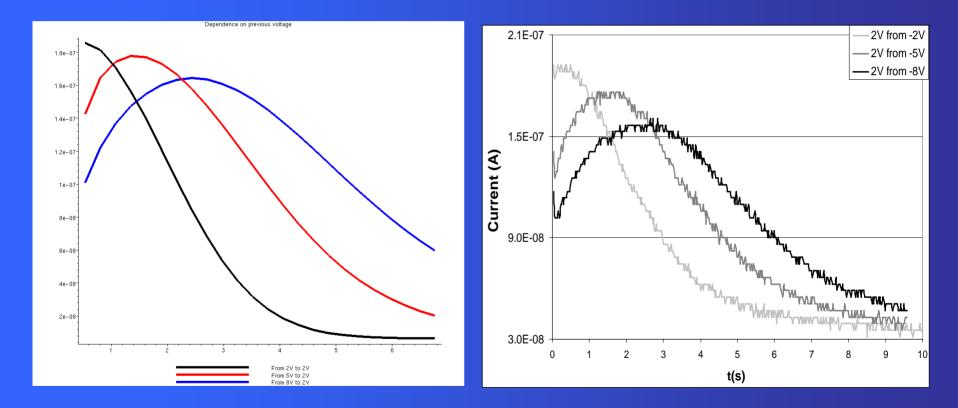
Results

Dependence on applied voltage



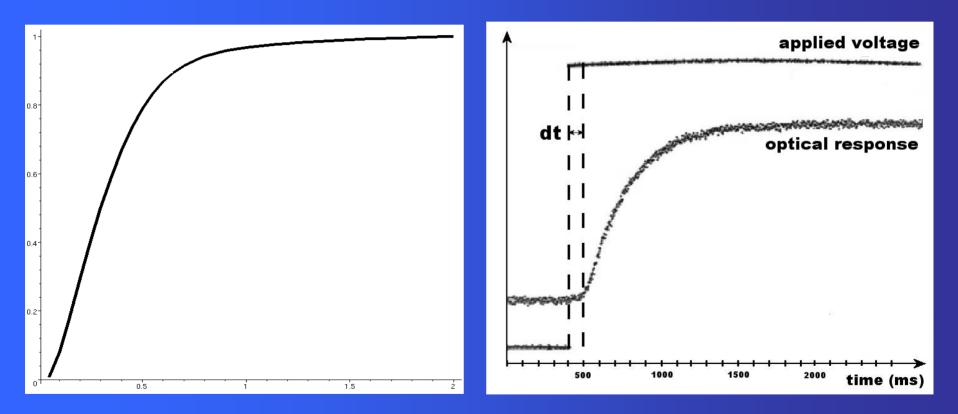
Results

Dependence on previous voltage



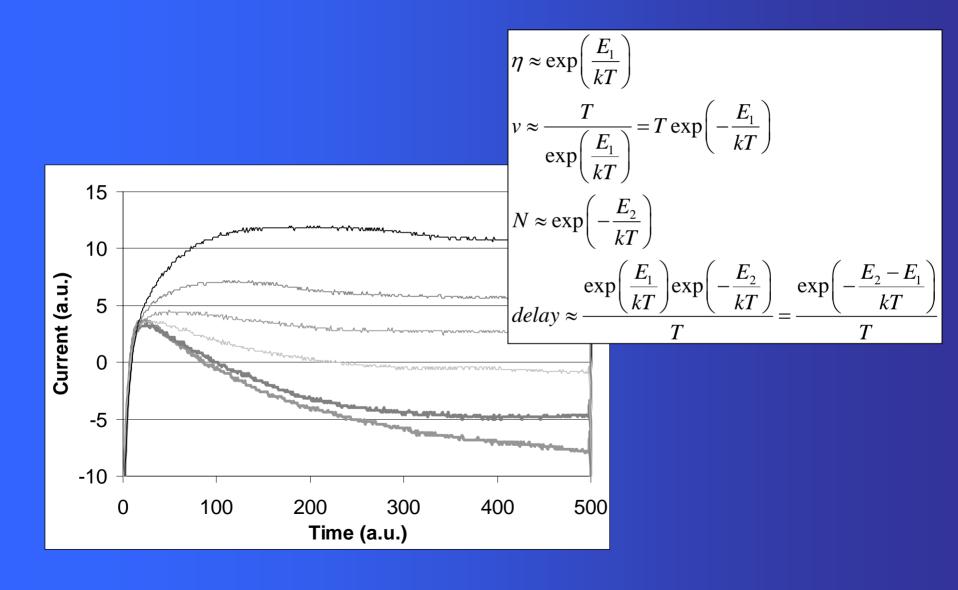
Optical response

Results



Results

Temperature dependence



Electrical & Optical simulation of EPIDs Physical, measurable parameters are used Importance of field screening and centrifugation

 \rightarrow Optimize displays production